



DESIGN AND FABRICATION OF AN ELECTRONIC SYSTEM FOR SIMULTANEOUS MEASUREMENT  
OF PRESSURE AND TEMPERATURE IN VACUUM DEPOSITION SYSTEMS

Tuwei<sup>1</sup> A.K., Karimi<sup>1</sup> P.M. and Wamwangi<sup>2</sup> D.M.

<sup>1</sup>Department of Physics, Kenyatta University, P.O. Box 43844-00100, Nairobi, Kenya

<sup>2</sup>School of Physics, University of Witwatersrand, Private Bag 3, 2050 Johannesburg, South Africa

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ABSTRACT

This paper described a simple automated instrumentation and measurement system that was designed to offer a more reliable and fast method of measuring process parameters: temperature and pressure, in thin film deposition systems. The designed computer based measuring system was based on thermocouple type K temperature sensor, MP20C-01-F2 pressure sensor, parallel port for interfacing and LabVIEW driver for accessing temperature and pressure data. The system was able to measure process parameter: temperature and pressure simultaneously when implemented in Edward auto 306 magnetron sputtering system and stored their values in a computer memory and retrieved at operator's will. It had a temperature and a pressure range of 0 to 3000 °C and 0 to  $1.01 \times 10^3$  mbar, respectively and temperature error of  $\pm 1$  °C. However, the designed system recorded varied pressure errors. In higher vacuum, pressure range of 1 to  $1 \times 10^{-2}$  mbar, the error was  $\pm 1 \times 10^{-2}$  mbar and in the lower range of  $1 \times 10^{-4}$  to  $1 \times 10^{-5}$  mbar, the error of  $1 \times 10^{-5}$  mbar was observed. These errors were within acceptable range and therefore, the system is viable to be used in thin film deposition systems to automate the measurement of process parameters: temperature and pressure to achieve high quality thin films.

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INTRODUCTION

In recent years, application of modern digital computers for instrument control [1] and measurement of physical parameters in industries has emerged as a promising area of achieving higher quality products and precise control and measurement of process parameters [3, 4, 5, 6, 7]. Thin film deposition in our research laboratories requires precise physical parameter control and accurate measurement. This ensures that high quality thin films are obtained that corresponds to specified values of process parameters under study. However, cheap and available current techniques for measuring temperature and pressure in thin film deposition systems lack memory and are manually operated. Therefore, vacuum deposition processes are largely controlled manually despite the fact that modern computers have a high speed of information processing and data storage [1, 9]. This approach is time consuming and prone to human errors while transferring process parameters from one application to another for analysis. Temperature and pressure, for instance, are of great importance in thin film preparation and affect largely on their properties [1] hence accurate measurement of these quantities is inevitable [11, 12]. Those that are automated and equipped with memories are quite expensive since they are based on PCI card for data acquisition or wireless transmission of data from the server to the clients [2, 10]. Other systems based on serial port interface are slow

[2, 8] compared to parallel port interface. Therefore this paper describes a computer based measuring system that measures and stores the deposition chamber temperature and pressure data in a computer memory in form of a text file. It's based on thermocouple type K temperature sensor, MP20C-01-F2 pressure sensor, parallel port for interfacing and LabVIEW driver for accessing data.

MATERIALS AND METHODS

Hardware designed procedures

The hardware design of the system comprised of the MP20C-01-F2 pressure sensor from Mindman Company, thermocouple type K temperature sensor and digital interface board designed in this project for communication between the computer and the sensors through the parallel port. The designed pressure sensor circuit and its associated 741 amplifier circuit are shown in figure 1. The sensor had output voltage range of 0 to 100 mV and operated with a  $V_{cc}$  of +5 V. The values of the resistors shown were determined using circuit maker 2000 software during the simulation of the circuit. The digital interface board designed as part of the project consisted of the low pass filter and ADC0804 analogue to digital converter, and AD8180 multiplexer which are the standard ICs. The parallel port computer interface was used to transfer pressure and temperature data between the digital interface board and the computer for processing and storage. The designed computer based measuring system was

fabricated on printed circuit board to minimize the capacitance observed on the breadboards.

### Software designed

The software driver, which was used to access the temperature and pressure data from the parallel port interface, was designed using LabVIEW programming language. This is a graphical programming language and codes appear as icons as opposed to text in text based programming. This minimized syntax errors that are usually encountered in text based programming during coding. The front panel was designed on LabVIEW environment using the numeric and Boolean indicators.

### Front panel for the software driver

The graphical user interface (GUI) depicted in figure 2 was designed using numeric and Boolean indicators. It displayed chamber temperature and pressure to the user during deposition of thin films in Edward auto 306 magnetron sputtering system. The on/off button on the front panel was used to activate and deactivate the software driver when data was to be access from the parallel port. The chamber temperature data was displayed in degrees celsius while chamber pressure displayed in mbars to the user.

### Block diagram for the software driver

The LabVIEW codes that were used to access temperature and pressure data from the parallel port interface are shown in figure 3. The codes manipulated the values of these parameters and stored them in a computer memory for retrieval by the user after the deposition process. The codes appeared as icons on the block diagram as opposed to text based codes that are composed of several lines of text in text based programming. In frame A, bidirectional property of the parallel port is enabled by writing decimal number 32 to the data port to be able to input temperature and pressure data from peripheral sensors used to the computer memory for processing. The SELECT signal of the multiplexer AD8180 used is also enabled for 20 ms to allow only temperature data to be read by the computer. In frame B, Temperature data is read from thermocouple type K temperature sensor used, processed, stored in computer memory in form of a text file and displayed to the user. In frame C, the SELECT signal of the multiplexer AD8180 is enabled for also 20 ms to allow only pressure data to be read by the computer. In the last frame D, pressure data is read from the sensor through the parallel port, processed, stored in computer memory in form of a text file and displayed to the user as indicated in figure 2. All the codes from frame A to frame D were executed in 80 ms and repeated again. Therefore, this time is so short that the user's eyes could not notice the delay in reading the temperature and pressure data separately. It appeared on the GUI simultaneously to the user.

### Testing the interface designed concept

The functionality of the designed computer based measuring system was tested in Edward auto 306 magnetron sputtering system as indicated in figure 4. The MP20C-01-F2 pressure sensor was fixed to the vacuum chamber through a vacuum

pipe and so to thermocouple type K temperature sensor. Their signal outputs were fed into the digital interfacing board designed and transmitted to the computer via the parallel port. The chamber pressure was measured by the designed system when Edward auto 306 magnetron sputtering system was pumping up (venting) and when it was pumping down (evacuating). The chamber temperature was measured when samples of SnSe were deposited in the chamber through evaporation process. These measurements were also done with pirani gauge for pressure and uninterfaced thermocouple type K already fitted in the vacuum chamber. The measured values are discussed in the result and discussion section 3.

## RESULTS AND DISCUSSIONS

### Pressure measurement

The measured pressure data are tabulated in tables 1 and 2 when Edward auto 306 magnetron sputtering system was venting and pumping down respectively. The pressure sensor MP20C-01-F2 works on piezoelectric principle. When a mechanical force is applied on the sensor, a voltage is induced across the positive and negative terminals of the sensor. When Edward auto 306 magnetron sputtering system was pumping up (venting), the number of air molecules was increasing in the vacuum chamber. Therefore collision of air molecules increased within the chamber hence pressure increased as observed in table 1 when the air continued to be pumped in. When Edward auto 306 magnetron sputtering system was pumping down, the number of air molecules reduced in the vacuum chamber. Therefore collision of air molecules decreased within the chamber hence pressure reduced as observed in table 2 when the air continued to be pumped out of the chamber.

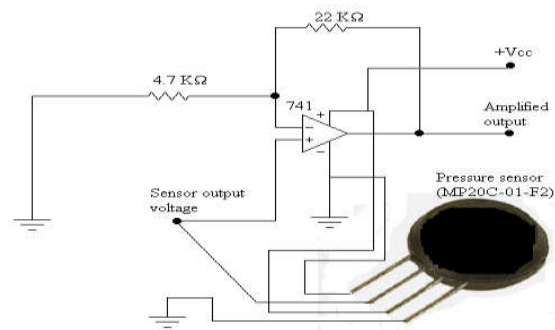


Fig 1: The designed circuit of the pressure sensor MP20C-01-F2.

### Temperature measurement

SnSe thin films were deposited on glass substrate in the ratio 1:1 in Edward auto 306 magnetron sputtering system using evaporation technique. During deposition process, the evaporation temperature of the samples was measured. Two thermocouple type K sensors, fixed in the chamber were used simultaneously to measure the evaporation temperature of the samples. One of the sensors was interfaced to the computer and the other to the standard thermocouple display. The measurements were repeated three times and their averages calculated. The evaporation temperatures measured by the designed electronic pressure and temperature measuring system and those from the standard thermocouple display are shown in table 3. It was observed that the designed electronic

LabVIEW Graphical user interface

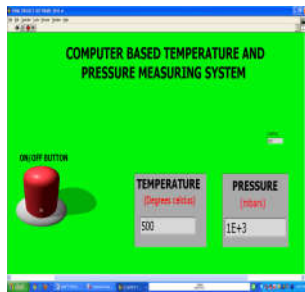


Fig 2: The GUI of the software driver for the designed electronic system.

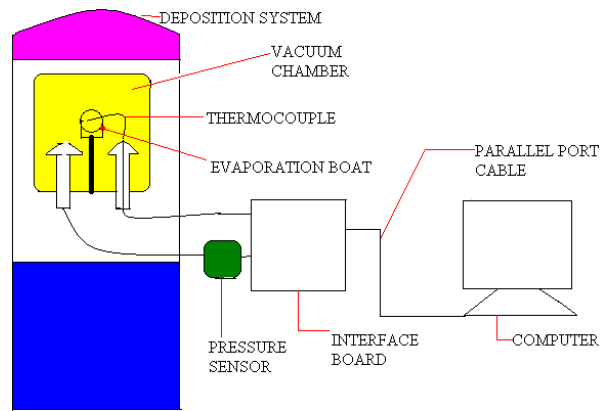
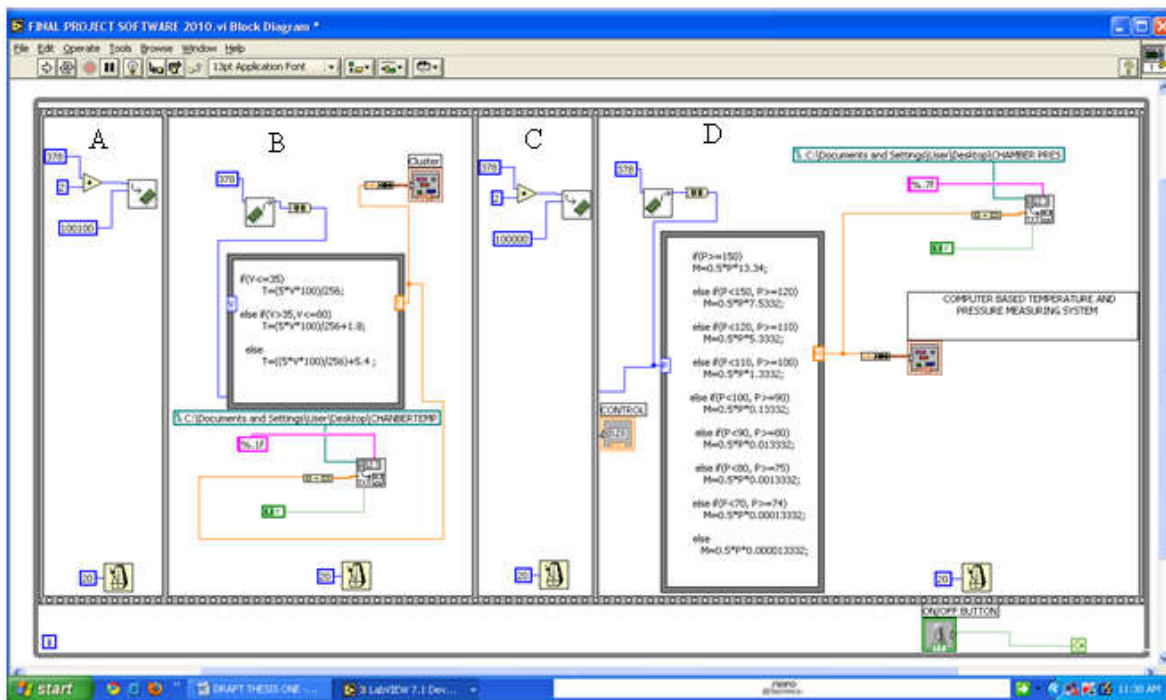


Fig 5: The designed hardware interfaced to the Laptop and to the Edward Auto 306 Magnetron Sputtering System



Laptop with parallel port  
Parallel port interface  
digital interface board  
Vacuum deposition system

Fig 4: Schematic of the designed computer based pressure measuring system tested in Edward auto 306 magnetron sputtering system

system had a temperature error of  $\pm 1\text{ }^\circ\text{C}$  which is within acceptable range.

**Conclusions**

The automated designed electronic measuring system described in this paper was tested in Edward auto 306 magnetron sputtering system and work quite well. It had a temperature and a pressure range of 0 to 3000  $^\circ\text{C}$  and 0 to  $1.01 \times 10^3$  mbar, respectively and temperature error of  $\pm 1\text{ }^\circ\text{C}$ . However, the designed system recorded varied pressure errors. In higher vacuum, pressure range of 1 to  $1 \times 10^{-2}$  mbar, the error was  $\pm 1 \times 10^{-2}$  mbar and in the lower range of  $1 \times 10^{-4}$  to  $1 \times 10^{-5}$  mbar, the error of  $1 \times 10^{-5}$  mbar was observed.. Therefore, the system is viable to be used in thin film deposition systems to automate the measurement of deposition pressure.

**REFERENCES**

1. Montanini, R. Squadrito, G. and Giacoppo, G. (2011). "Measurement of the Clamping Pressure Distribution in Polymer Electrolyte Fuel Cells Using Piezoresistive Sensor Arrays and Digital Image Correlation Techniques" *Power Sources*, 196: 8404-8493.
2. Benganem, M. (2010). "A Low Cost Wireless Data Acquisition System for Weather Station Monitoring" *Renewable Energy*, 35: 862-872.
3. Chaudhry, K.K. and Nakra, B.C. (2004). *Instrumentation, Measurement and Analysis*. New Delhi: Tata McGraw-Hill, pp. 113-455.
4. Lewin, D. (1996). *Theory and Design of Digital Computer Systems*. Great Britain: Wheaton and Company Limited, pp. 156-208.
5. Prasad, R. (2005). *Electronic Measurement and Instrumentation*. 3<sup>rd</sup> ed. Sarak Delhi: Khanna publishers, pp. 439-533.
6. Spencer, D.C. (1990). *Digital Design for Computer Data Acquisition*. New York: Cambridge University Press, pp. 302-556.
7. Tailor, L.B. (1992). *Digital Networks and Computer Systems*. 2<sup>nd</sup> ed. New York: John Wiley and Sons, pp. 139-155.
8. Wen-Bin, W. Jang-Yuan, L. and Qi-Jun, W. (2007). "The design of a Chemical Virtual Instrument based on LabVIEWfor Determining Temperatures and Pressures" *Journal of Automated Methods and Management in Chemistry*, 2007: 158-166.
9. Huang, Y. M. and Yang, S. (2008). "A Measurement Method for Air Pressures in Compressor Vane Segments" *Measurement*, 41: 835-841.
10. Lin, B. Xiaofeng, L. and Xingxi, H.(2011) "Measurement system for wind turbines noises assessment based on LabVIEW" *Measurement*, 44: 445-453.
11. Meng, X. Pan, W. Chen, X. Guo, Z. Wu,C (2011). "Temperature Measurements in a Laminar Plasma Jet Generated at Reduced Pressure" *Vacuum*, 85: 734-738.
12. Gao, R.X. Sah, S. and Mahayotsanun, N. (2010). "On-line Measurement of Contact Pressure Distribution at Tool-Workpiece Interfaces in Manufacturing Operations" *Manufacturing Technology*, 59: 399- 402.

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